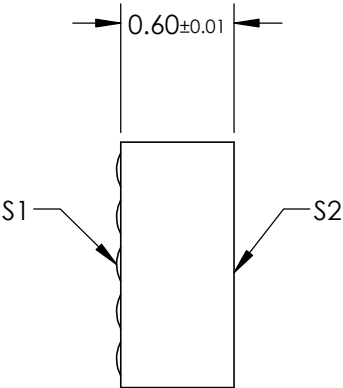
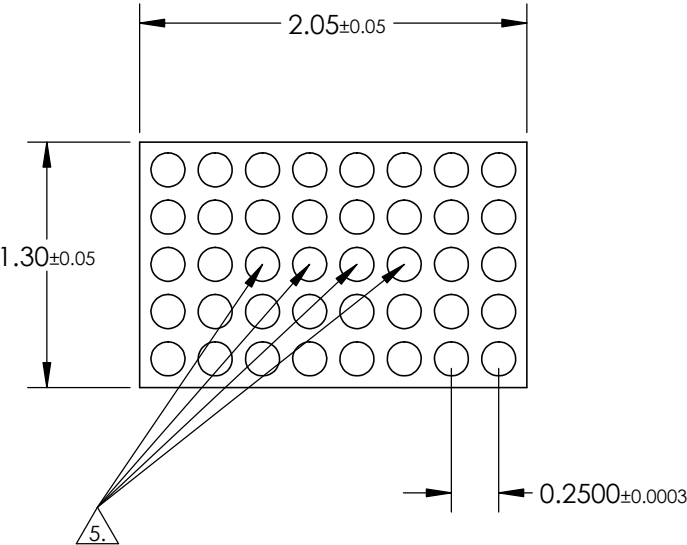
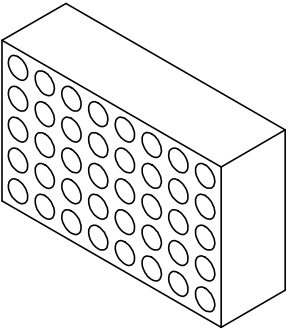


NOTES:

- 1. SUBSTRATE:  
Fused Silica
- 2. COATING (APPLY ACROSS COATING APERTURE):  
S1: R(AVG) ≤0.3% @ 1260 - 1675
- 3. WORKING DISTANCE (mm):  
0.01 in glue (nd = 1.5)  
0.015 in air
- 4. MODE FIELD DIAMETER (mm):  
Source: 0.0104  
Target: 0.085

5. ACTIVE LENSES CENTERED ON SUBSTRATE

6. ROHS: COMPLIANT



SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE  
DIMENSIONS ARE FOR REFERENCE ONLY

**FOR INFORMATION ONLY:  
DO NOT MANUFACTURE  
PARTS TO THIS DRAWING**

**Edmund Optics®**

THIRD ANGLE PROJECTION		TITLE	2.05 x 1.30mm, 0.192 ROC, 250µm Pitch, Fused Silica, 1 x 4 Linear Microlens Array	
ALL DIMS IN	mm	DWG NO	21172	SHEET 1 OF 1